

L Number	Hits	Search Text	DB	Time stamp
1	68	(island-like adj semiconductor\$2)same (base underl\$4 undercoat\$4)	USPAT; US-PGPUB	2004/09/03 20:09
2	119	(island\$1like island adj like)near5 (base underl\$4 undercoat\$4)	USPAT; US-PGPUB	2004/09/03 20:19
3	74	((island\$1like island adj like)near5 (base underl\$4 undercoat\$4)) and (lcd electroluminescent display\$2 soi silicon\$1on\$1insulator\$2 silicon adj2 insulator\$2 tft thin adj film adj transistor\$2)	USPAT; US-PGPUB	2004/09/03 20:15
4	26	(aluminum near2 oxide "Al.sub.2O.sub.3" aluminum adj nitride adj oxide "AlN.sub.xO.sub.1-x" nitride near2 aluminum "AlN.sub.x" AlSiON LaSiON ((aluminum) near2 (rare adj earth)) AlSiON LaSiON boron near2 nitride)and (((island\$1like island adj like)near5 (base underl\$4 undercoat\$4)) and (lcd electroluminescent display\$2 soi silicon\$1on\$1insulator\$2 silicon adj2 insulator\$2 tft thin adj film adj transistor\$2))	USPAT; US-PGPUB	2004/09/03 20:11
5	140	(island\$1like island adj like)and (base underl\$4 undercoat\$4)	EPO; JPO; DERWENT	2004/09/03 20:14
6	11	(((island\$1like island adj like)and (base underl\$4 undercoat\$4)) and (lcd electroluminescent display\$2 soi silicon\$1on\$1insulator\$2 silicon adj2 insulator\$2 tft thin adj film adj transistor\$2)	EPO; JPO; DERWENT	2004/09/03 20:15
7	2	(island\$1like island adj like)near5 (aluminum near2 oxide "Al.sub.2O.sub.3" aluminum adj nitride adj oxide "AlN.sub.xO.sub.1-x" nitride near2 aluminum "AlN.sub.x" AlSiON LaSiON ((aluminum) near2 (rare adj earth)) AlSiON LaSiON boron near2 nitride)	USPAT; US-PGPUB	2004/09/03 20:23
8	3	(island\$1like island adj like)and (aluminum near2 oxide "Al.sub.2O.sub.3" aluminum adj nitride adj oxide "AlN.sub.xO.sub.1-x" nitride near2 aluminum "AlN.sub.x" AlSiON LaSiON ((aluminum) near2 (rare adj earth)) AlSiON LaSiON boron near2 nitride)	EPO; JPO; DERWENT	2004/09/03 20:21
9	95	(soi silicon\$1on\$1insulator\$2 silicon adj insulat\$4)and (island-like adj semiconductor\$2)and (base underl\$4 undercoat\$4)	USPAT; US-PGPUB	2004/09/03 20:23
10	1	(soi silicon\$1on\$1insulator\$2 silicon adj insulat\$4)and (island-like adj semiconductor\$2)and (base underl\$4 undercoat\$4)	EPO; JPO; DERWENT	2004/09/03 20:23
11	103	((pattern\$4 etch\$4 taper tapering tapered)near5(aluminum near2 oxide "Al.sub.2O.sub.3" aluminum adj nitride adj oxide "AlN.sub.xO.sub.1-x" nitride near2 aluminum "AlN.sub.x" AlSiON LaSiON ((aluminum) near2 (rare adj earth)) AlSiON LaSiON boron near2 nitride))near17(substrate translucent plastic quartz glass))and (lcd electroluminescent display\$2 soi silicon\$1on\$1insulator\$2 silicon adj2 insulator\$2 tft thin adj film adj transistor\$2)	USPAT; US-PGPUB	2004/09/03 20:27
12	64	(((thick thicker thinner)near5(aluminum near2 oxide "Al.sub.2O.sub.3" aluminum adj nitride adj oxide "AlN.sub.xO.sub.1-x" nitride near2 aluminum "AlN.sub.x" AlSiON LaSiON ((aluminum) near2 (rare adj earth)) AlSiON LaSiON boron near2 nitride))near17(substrate translucent plastic quartz glass))and (lcd electroluminescent display\$2 soi silicon\$1on\$1insulator\$2 silicon adj2 insulator\$2 tft thin adj film adj transistor\$2)	USPAT; US-PGPUB	2004/09/03 20:26
13	454	(((thick thicker thinner)near5(alumina ceramic))near17(substrate translucent plastic quartz glass))and (lcd electroluminescent display\$2 soi silicon\$1on\$1insulator\$2 silicon adj2 insulator\$2 tft thin adj film adj transistor\$2)	USPAT; US-PGPUB	2004/09/03 20:27
14	643	(((pattern\$4 etch\$4 taper tapering tapered)near5(alumina ceramic))near17(substrate translucent plastic quartz glass))and (lcd electroluminescent display\$2 soi silicon\$1on\$1insulator\$2 silicon adj2 insulator\$2 tft thin adj film adj transistor\$2)	USPAT; US-PGPUB	2004/09/03 20:32
15	145	(((pattern\$4 etch\$4 taper tapering tapered)near5(alumina))near17(substrate translucent plastic quartz glass))and (lcd electroluminescent display\$2 soi silicon\$1on\$1insulator\$2 silicon adj2 insulator\$2 tft thin adj film adj transistor\$2)	USPAT; US-PGPUB	2004/09/03 20:29
16	134	(semiconductor with crystal crystalline single adj crystal)and (((thick thicker thinner)near5(alumina ceramic))near17(substrate translucent plastic quartz glass))and (lcd electroluminescent display\$2 soi silicon\$1on\$1insulator\$2 silicon adj2 insulator\$2 tft thin adj film adj transistor\$2))	USPAT; US-PGPUB	2004/09/03 20:30

17	10	(((pattern\$4 etch\$4 taper tapering tapered)near5(aluminum near2 oxide "Al.sub.2O.sub.3" aluminum adj nitride adj oxide "AlN.sub.xO.sub.1-x" nitride near2 aluminum "AlN.sub.x" AlSiON LaSiON ((aluminum) near2 (rare adj earth)) AlSiON LaSiON boron near2 nitride))and(substrate translucent plastic quartz glass))and (lcd electroluminescent display\$2 soi silicon\$1on\$1insulator\$2 silicon adj2 insulator\$2 tft thin adj film adj transistor\$2)	EPO; JPO; DERWENT	2004/09/03 20:33
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